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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Application Number	10/695,724
Filing Date	October 28, 2003
First Named Inventor	Eric Frayssinet
Art Unit	2823
Examiner Name	Rori Burch
Attorney Docket Number	15675P314CX

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No.'	Include name of the author (in CAPITAL LETTERS), title of the artide (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²
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Examiner Signature	Kuen	Min	Lu	Date Considered	2/7/2015		
*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication.							

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Examiner	Cite	Document Number	Publication Date or Issue Date MM-DD-YYYY	Name of Patentee or	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
Initials*	No.'	Number - Kind Code ² (if known)		Applicant of Cited Document			
Je	/	US-6475882	11-05-2002	Sakai et al.			
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Examiner	Cite No.¹	Foreign Patent Document	240.00		Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	76
Initials*		Country Code ³ - Number ⁴ Kind Code ⁶ (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document		
7º		0506146 A2	04-06-1981	Massachusetts Institute of Technology		
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